## Supporting Information

## UV-Ozone Surface Pretreatment for High Quality ALD-Grown Ultrathin Coatings on Bismuth Oxyhalide Photocatalysts

Nitai Arbell<sup>a,b</sup>, Shakked Regev<sup>a,b</sup>, Yaron Paz<sup>\*a,b</sup>

a. The Russell Berrie Nanotechnology Institute, Technion-Israel Institute of Technology, Haifa 3200003, Israel.

b. The Wolfson Department of Chemical Engineering, Technion-Israel Institute of Technology.

Email: Paz@technion.ac.il

\*Corresponding author



**Fig S1** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOCl in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C following UV-ozone



treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Cl (F) atoms.

**Fig S2** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOCI in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C without UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Cl (F) atoms



**Fig S3** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOBr in an SiO2 binder coated with 10 cycles of Al2O3 ALD at 80°C following UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Br (F) atoms.



**Fig S4** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOBr in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 80°C without UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Br (F) atoms.



**Fig S5** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOBr in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C following UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Br (F) atoms.



**Fig S6** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOBr in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C without UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Br (F) atoms.



**Fig S7** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOI in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 80°C following UV-ozone



treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and I (F) atoms.

**Fig S8** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOI in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 80°C without UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and I (F) atoms.



**Fig S9** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOI in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C following UV-ozone



treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and I (F) atoms.

**Fig S10** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for BiOI in an SiO<sub>2</sub> binder coated with 10 cycles of  $Al_2O_3$  ALD at 40°C without UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and I (F) atoms.



**Fig S11** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for pure BiOCl-particle films with 10 cycles of  $Al_2O_3$  ALD at (A1-E1) 40°C, (A2-E2) 60°C, (A3-E3) 80°C, following UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Cl (F) atoms.



**Fig S12** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for pure BiOBr-particle films with 10 cycles of  $Al_2O_3$  ALD at (A1-E1) 40°C, (A2-E2) 60°C, (A3-E3) 80°C, following UV-ozone treatment. EDS legend: O (B), Al (C), Si (D), Bi (E) and Br (F) atoms.



**Fig S13** SEM micrograph (A) and EDS elemental maps (B-F) of the highlighted area for pure BiOI-particle films with 10 cycles of  $AI_2O_3$  ALD at (A1-E1) 40°C, (A2-E2) 60°C, (A3-E3) 80°C, following UV-ozone treatment. EDS legend: O (B), AI (C), Si (D), Bi (E) and I (F) atoms.



**Fig S14** FTIR spectra measured for thin BiOX layers pressed on KBr pellets, with (blue) and without (red) UVOC treatment. Presented are traces for (A) BiOCI, (B) BiOBr and (C) BiOI.



**Fig S15** (A) FTIR spectra measured for KBr pellets, with (blue) and without (red) UVOC treatment, compared to a vacuum background. (B) Difference spectrum of the KBr before UVOC subtracted from the KBr following UVOC treatment.



**Fig S16** High resolution XPS Al2p peaks for samples with (continuous line) and without (dashed line) UV-ozone pre-treatment prior to coating with (A) 10 cycles, (B) 5 cycles, and (C) 1 cycle of  $Al_2O_3$  on (1) BiOCl, (2) BiOBr, and (3) BiOl.



**Fig S17** High resolution XPS Bi4f peaks for samples with (continuous line) and without (dashed line) UV-ozone pre-treatment prior to coating with (A) 10 cycles, (B) 5 cycles, and (C) 1 cycle of  $AI_2O_3$  on (1) BiOCI, (2) BiOBr, and (3) BiOI.



**Fig S18** High resolution XPS O1s peaks for samples with (continuous line) and without (dashed line) UV-ozone pre-treatment prior to coating with (A) 10 cycles, (B) 5 cycles, and (C) 1 cycle of  $Al_2O_3$  on (1) BiOCl, (2) BiOBr, and (3) BiOl.



**Fig S19** High resolution XPS Cl2p (1), Br2d (2) and I3d (3) peaks for samples with (continuous line) and without (dashed line) UV-ozone pre-treatment prior to coating with (A) 10 cycles, (B) 5 cycles, and (C) 1 cycle of  $Al_2O_3$  on (1) BiOCl, (2) BiOBr, and (3) BiOI.



**Fig S20** Bi4f line in a BiOCl sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, deconvoluted into an asymmetric Bi-metal peak at 155.5 eV (FWHM = 1.3



eV) and a symmetric Bi-oxide peak at 157.7 eV (FWHM = 1.5 eV).

**Fig S21** O1s line in a BiOCl sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, deconvoluted into a symmetric oxide peak at 529.2 eV (FWHM = 1.6 eV) and a symmetric hydroxide peak at 531.5 eV (FWHM = 2.3 eV).



**Fig S22** Al2p line in a BiOBr sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, deconvoluted into a symmetric Al<sub>2</sub>O<sub>3</sub> peak at 73.8 eV (FWHM = 1.7 eV).



**Fig S23** Cl2p line in a BiOCl sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, showing two peaks with a spin-orbit splitting of 1.6 eV, with a symmetric peak at 197.0 eV (FWHM = 1.3 eV).



**Fig S24** Br3d line in a BiOBr sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, deconvoluted into two unallocated peaks with a spin-orbit splitting of 1.05 eV, a symmetric peak at 66.5 eV (FWHM = 1.4 eV) and a symmetric peak at 67.4 eV (FWHM = 1.1 eV).



**Fig S25** I3d5 line in a BiOI sample coated with 1 cycle of ALD at  $60^{\circ}$ C, following UVOC pretreatment, deconvoluted into a symmetric alkali oxide peak at 618.7 eV (FWHM = 1.6 eV) and an asymmetric (IV) oxidation state peak at 623.4 eV (FWHM = 1.2 eV).

**Table S1** T-test p-values for the comparison of kinetic data between samples coated with or without UVOC pretreatment. Data is shown for 5, 10, and 20 ALD cycle coatings deposited at 60°C, for each photocatalyst, as well as across all BiOX types.

Coating Thickness	5 Cycles	10 Cycles	20 Cycles
BiOCI	0.0174	0.000637	0.492
BiOBr	0.00966	0.211	0.25
BiOI	0.0207	0.0234	0.00909
All Catalysts	0.0151	0.0488	0.0639